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(21) International Application Number: PCT/US91/05860 (22) International Filing Date: 17 August 1991 (17.08.91) (30) Priority data: 580,696                      10 September 1990 (10.09.90) US (71) Applicant: OLIN CORPORATION [US/US]; 350 Knotter Drive, P.O. Box 586, Cheshire, CT 06410-0586 (US). (72) Inventors: MAHULIKAR, Deepak ; 20 Martleshamheath Lane, Madison, CT 06443 (US). FISTER, Julius, C. ; 28 Norwood Street, Hamden, CT 06518 (US). VIOLETTE, Gerald, N. ; 714 Newhall Street, #3, Hamden, CT 06517 (US).		(74) Agents: ROSENBLATT, Gregory, S. et al.; Olin Corporation, 350 Knotter Drive, P.O. Box 586, Cheshire, CT 06410-0586 (US).  (81) Designated States: AT (European patent), AU, BB, BE (European patent), BF (OAPI patent), BG, BJ (OAPI patent), BR, CA, CF (OAPI patent), CG (OAPI patent), CH (European patent), CI (OAPI patent), CM (OAPI patent), DE (European patent), DK (European patent), ES (European patent), FI, FR (European patent), GA (OAPI patent), GB (European patent), GN (OAPI patent), GR (European patent), HU, IT (European patent), JP, KP, KR, LK, LU (European patent), MC, MG, ML (OAPI patent), MR (OAPI patent), MW, NL (European patent), NO, PL, RO, SD, SE (European patent), SN (OAPI patent), SU <sup>+</sup> , TD (OAPI patent), TG (OAPI patent).  Published <i>With international search report.</i>	
(54) Title: LEADFRAME FOR MOLDED PLASTIC ELECTRONIC PACKAGES			
(57) Abstract <p>A composite leadframe (10) for an electronic package (32') is provided. The leadframe (10) has an electrically conductive core (35) with a polymer layer (42) coating a portion of the core (35) to increase the adhesive bond between leadframe (10) and molding resin (34). The improved adhesion prevents water vapor from accumulating under the leads (18) and die attach paddle (24) thereby minimizing the popcorn effect.</p>			

# + DESIGNATIONS OF "SU"

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## LEADFRAME FOR MOLDED PLASTIC ELECTRONIC PACKAGES

This invention relates generally to leadframes for molded plastic electronic packages. More particularly, the invention relates to methods for increasing the adhesion between the leadframe and the molding resin to minimize the entrapment of water vapor.

Molded plastic packages are widely used to house microelectronic devices, such as silicon based semiconductor integrated circuits. The molded plastic packages are characterized by low cost, ease of assembly and adequate protection of the device from water vapor and other sources of corrosion. Usually, the device is mounted on a centrally positioned die attach paddle. The electronic device is then electrically interconnected to the inner ends of a plurality of leads which approach the die attach paddle from at least one side and up to all four sides of the paddle. Electrical interconnection is typically by wire bonding or tape automated bonding. Following electrical interconnection, the centrally positioned die attach paddle, electronic device and inner portion of the leadframe are encapsulated in a molding resin by a process such as transfer molding. The resin forms a hard, relatively moisture impervious shell protecting both the semiconductor device and the electrical connections.

Subsequent to encapsulation, the outer leads of the leadframe are frequently soldered to a printed circuit board or other external electrical device. During soldering, the temperature of the encapsulated package may rise to from about 200°C to about 260°C. Particularly susceptible to temperature increases are leadless chip carriers such as plastic surface mount components. Any water vapor trapped within the package

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rapidly expands. One site for the accumulation of water is at the interface between the molding resin and the die attach paddle. When the accumulated water vapor expands, the base of the molded plastic package is deformed leading to what is known as the "popcorn effect".

When the popcorn effect is severe, the molding resin can fracture. The fractures form conduits allowing water vapor and other corrosives to accumulate in close proximity to the bonding wires and integrated circuit device. Water enters the package by many means. Exposure of the molding resin to moisture either before or after encapsulation can lead to a build-up of moisture within the package. The Institute for Interconnecting Packaging Electronic Circuits (IPC) has recently proposed shipping plastic surface mount components in hermetic containers to prevent the build-up of moisture.

A second source of moisture is penetration along metal/plastic interfaces. The adhesion between the molding resin and the metallic leadframe is primarily mechanical in nature. Frequently, a gap exists between the metallic leadframe and the plastic encapsulant. Moisture travels through the gap and accumulates under the die attach paddle.

Various means have been proposed to limit the ingress of water vapor. U.S. Patent No. 4,866,506 to Nambu et al discloses forming a vent hole in the molding resin. The vent hole interconnects the backside of the die attach paddle with the atmosphere so moisture accumulating under the paddle will dissipate when heated. U.S. Patent No. 4,855,807 to Yamaji et al discloses vent holes located along the tie bars which support the die attach paddle.

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To minimize separation between the molding resin and the metallic leadframe, several means to improve the adhesion have been proposed. These solutions include both means to increase mechanical adhesion and chemical adhesion. To improve mechanical locking, various configurations of holes, grooves and hemispheres have been formed in both the leads and the die attach paddle. The holes and deformations increase the surface area of the leadframe component and also provide crevices for enhanced mechanical locking. For example, U.S. Patent No. 4,862,246 to Masuda et al discloses forming a series of hemispherical depressions on the die attach paddle. These depressions increase the adhesion of the die attach paddle to the molding resin increasing the resistance to humidity.

A dull layer of nickel applied to a copper alloy leadframe has been found to increase the strength of an epoxy bond as disclosed in U.S. Patent No. 4,888,449 to Crane et al. U.S. Patent No. 4,707,724 to Suzuki et al discloses coating the die attach paddle with an alloy of tin/nickel or iron/nickel which will increase the adhesive strength and minimize peeling.

Certain chemical solutions also increase the adhesive strength of the bond between copper and a polymer. U.S. Patent No. 4,428,987 to Bell et al discloses pretreating the copper surface to improve adhesion. The surface is electrolytically reduced and then coated with a solution such as benzotriazole.

While the prior art processes are effective to increase the adhesion between a molding resin and a metal leadframe, the bond is still inadequate. Channels permit the ingress of water vapor. Absent complete sealing of the channels, popcorning is still a problem.

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Accordingly, it is an object of the invention to provide improved adhesion between a metal leadframe and a polymer molding compound which will be suitable for preventing the ingress of moisture vapor along the metal/polymer interface. This is achieved by coating the leadframe with a polymer which has good adhesion to both the metallic leadframe and the molding resin. It is a feature of the invention that the inner lead portion of the leadframe is coated with the polymer except for the lead tips. The lead tips are preferably polymer free to facilitate wire bonding. Yet another feature of the invention is that at least the side of the die attach paddle opposite the electronic device is coated with polymer to prevent the accumulation of water vapor. Still another feature of the invention is that a layer of a second material may be disposed between the metal leadframe and polymer coating to increase bond strength. It is an advantage of the invention that the polymer coating is preferably an epoxy. The epoxy may be provided in either sheet form or as a liquid. Yet another advantage of the invention is that, following accelerated testing in a pressure cooker, a five times improvement in bond strength is noted after five hours.

In accordance with the invention, there is provided a composite leadframe for an electronic package. The leadframe core is a conductor having a plurality of leads with inner and outer portions. The inner lead portions define a central aperture. A first polymer coats at least a portion of the inner leads.

The objects, features and advantages discussed above will become more apparent from the specification and drawings which follow.

Figure 1 shows in top planar view a leadframe including a centrally positioned die attach pad as known in the prior art.



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Figure 2 shows in cross sectional representation of a prior art molded package damaged by the popcorn effect.

Figure 3 shows in cross sectional representation a molded plastic electronic package including the composite leadframe of a first embodiment of the invention.

Figure 4 shows in cross sectional representation a molded plastic electronic package including the composite leadframe of a second embodiment of the invention.

Figure 5 shows in cross sectional representation a method for evaluating adhesion.

Figure 6 shows in cross sectional representation a composite leadframe incorporated in a metal package in accordance with an embodiment of the invention.

Figure 1 shows in top planar view a quad leadframe 10 as known in the prior art. The leadframe 10 contains a plurality of leads 12. The leads are made up of outer lead portions 14 supported by tie bar 16. The opposite ends of the leads 12 form inner leads 18. The inner leads 18 terminate at inner lead tips 20. The inner lead tips 20 serve to define a centrally positioned cavity 22.

A die attach paddle 24 is preferably located within the centrally positioned cavity 22. The die attach paddle provides a site for supporting an electronic device 28 in close proximity to the inner leads 18. The die attach paddle 24 is held in place by one or more tie bar supports 26. The tie bar supports 26 extend from the centrally positioned die attach paddle 24 to tie bars 16.

The leadframe 10 includes the leads 12 and die attach paddle 24 and may be manufactured from any electrically conductive material. The leadframe has a thickness of from about .13 mm (.005 inches) to about

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.51 mm (0.20 inches) for packages having external leads. Most commonly, the leadframes are about .25 mm (.010 inches) thick. For quad leadframes in surface mounted packages, the leadframe thickness is typically  
5 about .15 mm (.006 inches). For tape automated bonding (TAB) leadframes, the thickness may be as low as .036 mm (.0014 inches).

The leadframes are usually manufactured from iron/nickel containing alloys such as 42%  
10 nickel/remainder iron. The alloys have a coefficient of thermal expansion close to that of a semiconductor integrated circuit device. Alternatively, copper or copper based alloys are employed to exploit the high electrical and thermal conductivity of copper based  
15 materials. The composite leadframes of the present invention are equally suitable for iron/nickel containing alloys and copper based alloy leadframes as well as any other metallic material.

Bonded to the die attach paddle is an integrated  
20 circuit device 28. The device 28 is bonded to the die attach paddle by any conventional die attach material such as a low melting solder like lead/tin or eutectic solder like gold/tin or gold/silicon. Alternatively, an adhesive such as a silver filled epoxy may be used.  
25 When the leadframe is formed from copper or a copper based alloy, the die attach material is preferably compliant to compensate for coefficient of thermal expansion mismatch. Bond wires 30 electrically interconnect the integrated circuit device 28 to the  
30 inner lead tips 20. The bond wires may be thin aluminum, gold or copper wires or an etched copper foil such as employed in tape automated bonding.

The leadframe 10 with integrated circuit device 28 bonded to the centrally positioned die attach paddle 22  
35 and electrically connected to the inner lead ends 20 is



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then encapsulated. The assembly is placed in a mold cavity and a suitable molding compound is introduced to the cavity such that the inner leads 18 and centrally positioned die attach paddle 24 are encapsulated.

5 Typical molding resins are epoxies, silicones and urethanes. Epoxy resins are most widely used for device encapsulation. The epoxy resins are characterized by low shrinkage during curing, good adhesion to most surfaces, environmental stability and ease of

10 processing. Epoxy novolacs incorporating phenolic curing agents are commonly used. Fillers such as silica or alumina may be added to the epoxy in concentrations of up to 75% to improve the properties of the molded package. The fillers reduce curing shrinkage, increase

15 the strength of the epoxy, lower its thermal expansivity and in the case of alumina, increase thermal conductivity. The epoxies are generally colored black to maximize infrared radiation absorption. IR is typically used to solder the assembled package to a

20 printed circuit board.

The epoxy resin is liquified in a hot chamber. Liquid resin is then forced by a ram into a heated mold containing the device being encapsulated and allowed to solidify and cure about the device. The entire process

25 takes only a few minutes enabling high production rates.

Figure 2 shows a plastic encapsulated package 32 illustrating the moisture absorption problems of the prior art. The inner lead ends 18 and centrally positioned die attach paddle 24 are encapsulated with a

30 block of molding resin 34. Adhesion between the metal leadframe and the molding resin 34 is not ideal. Also, the metal leadframe and polymer molding resin have different coefficients of thermal expansion. As both cool, they contract at different rates. As a

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consequence of the relatively poor adhesion between the metallic leadframe and the molding resin and the different coefficients of thermal expansion, a gap 36 may form between the metallic components and the molding resin. The gap serves as a channel for moisture and other contaminants into the sealed package. The gap also provides a site for the accumulation of moisture. Particularly, the gap 37 under the die attach paddle 24 is a problem. The gap 37 is a sealed cavity. Subsequent to molding, the package is frequently heated. For example, infrared radiation may be used to heat the outer leads 14 for soldering. The package 32 is heated to a temperature of from about 200°C to about 260°C. The heat causes moisture trapped within the gap 36,37 to expand. The expanding water vapor causes the base 38 of the package 32 to bulge. This bulging is commonly referred to as the popcorn effect. The bulging may be sufficiently severe to form fractures 40 in the molding resin 38.

The bulging and fractures are not desirable. Bulging changes the surface outline of the package and may prevent smooth insertion into a printed circuit board. Bulging is cosmetically unacceptable. The fractures 40 serve as a means for the ingress of moisture and corrosive elements to the die attach paddle 24 and integrated circuit device 28. The contaminants corrode the fine circuits formed on the face of the integrated circuit device as well as the bonding wires 30. The bulging can distort or break the brittle silicon based electronic device. Bulging can also cause the bond wires to fracture.

The popcorn effect problem can be eliminated by preventing the accumulation of water vapor in the gap 37 below the die attach pad 24. The accumulation of water vapor is minimized by improving the adhesion between the

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molding resin 34 and the metallic leadframe. Applicants have achieved this objective by the composite leadframe of the invention.

An integrated circuit device 28 is electrically  
5 connected to inner lead tips 20 by bonding wires 30. The molding resin 34 encapsulates both the inner lead portions 18 and the device. If a die attach paddle 28 is used, it is fully encapsulated as well.

Figure 3 shows an encapsulated package 32' in  
10 accordance with a first embodiment of the invention. The leadframe 10 is a composite structure having a core conductor 35 and a first polymer 42 coating at least a portion of the inner leads 18. A portion of the leadframe 10 is coated with a layer of the first polymer  
15 42. Any polymer which adheres well to both copper and the molding resin may be used. Among the preferred polymers are polyimides, epoxies, acrylics and urethanes. Epoxies are most preferred due to the strong adhesive bonds which form and the thermosetting  
20 characteristics of the resin.

If a die attach paddle 24 is incorporated into the leadframe 10, the first polymer may cover the first 47 and second 44 major surfaces of the die attach paddle. Most preferably, the first polymer 42 coats at least the  
25 second major surface 44. The portion of the inner leads coated includes the entire section of the inner lead which is encapsulated within the molding resin 34 except for the inner lead tips 20. The first polymer may extend outwardly from the walls 46 of the package 32' to  
30 eliminate the formation of a leadframe/molding resin interface.

The inner lead tips 20 are preferably not coated with the epoxy layer 42 to facilitate bonding of bond wires 30. Aluminum or gold-based bonding wires are  
35 usually joined to the leadframe by thermocompression bonding which requires a metal to metal interface.

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Copper foil leads such as used in tape automated bonding are joined by a similar technique. However, it is within the scope of the invention for the entire inner lead portion to be coated. The side of the inner lead tip opposite the bond wire may be coated. The polymer layer 42 may be deposited subsequent to wire or TAB bonding and coat the bond and entire inner lead tip 20.

The first major surface 47 of the die attach paddle 24 contacts the integrated circuit device 28 and may also be coated with a polymer. The selection of polymer on this surface is dependent on the requirements of the device 28. If the device is to be electrically isolated from the paddle, then any suitable non-conductive polymer may be used, such as the first polymer 42. If the paddle is to provide a ground or reverse voltage bias, then a second electrically conductive polymer is selected. A silver filled epoxy is an exemplary conductive polymer for the surface.

One suitable polymer is a thermoplastic polyolefin such as polyethylene or polypropylene, preferably containing a grafted metal deactivator and primary antioxidant as disclosed in U.S. Patent No. 4,812,896 to Rothgery et al. Other suitable first polymers include polyimides, epoxies, acrylics and urethanes.

The most preferred first polymer is an epoxy such as Hysol XEA9485NM manufactured by The Dexter Company (Pittsburg, CA). The epoxy layer is selected to have a thickness effective to coat the metal leadframe and die attach paddle. Preferably, the thickness is from about .013 mm (.0005 inches) to about .51 mm (.020 inches) and most preferably from about .025 mm (.001 inches) to about .13 mm (.005 inches). The epoxy is applied either as a liquid or in sheet form.

If applied as a liquid, the leadframe is first degreased in a suitable solvent such as acetone or

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propanol. The portions of the inner leads which are to remain epoxy free are masked with a suitable masking agent. The leadframe is then dipped in a solution containing the epoxy dissolved in a solvent. The solvent is then evaporated depositing the polymer on the leadframe.

More preferably, the epoxy layer 42 is applied in sheet form. An epoxy preform having the desired dimensions is stamped. The leadframe 10 is then heated to a temperature sufficient to tack the epoxy. "Tack" is used in its conventional sense within the art. The epoxy is heated to a temperature sufficient to promote bonding to the leadframe but insufficient to initiate complete polymerization. For a .13 mm (.005 inch) film, a suitable thermal profile for tacking is 3 minutes at 100°C. Complete bonding occurs during encapsulation and soldering.

The epoxy sheet may be cut or stamped into the desired shape. The sheet is held in place during tacking by any suitable fixturing means. Sheets of different polymers may be simultaneously tacked, if, for example, a conductive adhesive is required in the chip bonding face of the die attach paddle. High lead count leadframes (i.e., a quad leadframe having on the order of 200 leads) require a tie bar to prevent lead distortion or shorting during assembly. The epoxy sheet of the invention is capable of holding the leads in place eliminating the need for the tie bar.

The epoxy 42 bonds more securely than the molding resin 34 to the metallic leadframe 10. The molding resin forms a secure bond to the epoxy 42. The bond between the molding resin and the composite leadframe which includes epoxy layers 42 is superior to that of the molding resin to the leadframe. While the composite leadframe illustrated in Figure 3 is superior to the



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prior art, the strength of the adhesive bond may be further increased and the popcorn effect further reduced by disposing an adhesion enhancing layer between the leadframe and the epoxy layer as illustrated in Figure 4.

5       An adhesion enhancing layer 48 is disposed between the leadframe 10 and the epoxy layer 42. The adhesion promoting layer 48 may be a roughened surface layer to enhance mechanical bonding. For example, certain copper alloys such as C638 (nominal composition 95% by weight  
10   copper, 2.8% aluminum, 1.8% silicon and 0.4% cobalt) are capable of forming a refractory oxide layer in situ. By proper selection of temperature and the addition of a small amount of water vapor to the furnace atmosphere, a layer of alumina is formed on the surface of the copper  
15   alloy leadframe. Alternatively, a dull metal coating, such as nickel, may be deposited on the surface of the conductor by a process such as electrolytic deposition. Certain phosphate coatings are also known to enhance adhesion between copper and epoxy.

20       The adhesion promoting layer 48 may also be a polymer which chemically bonds to both copper and epoxy such as benzotriazole and benzothiazole. The adhesion promoting compound preferably includes a coupling agent which chemically bonds the compound to the leadframe.  
25   When the leadframe is copper or a copper alloy, suitable adhesion promoting layers include mercaptoester, 5-carboxy-benzotriazole, 5-(1-aminoethyl-amido)-benzotriazole and 5-amido-benzotriazole. Another suitable adhesion promoting compound is ethylene vinyl acetate.  
30   The thickness of the adhesion promoting layer is under about 500 angstroms. Preferably, the thickness of the layer is from about 20 to about 100 angstroms.

35       The advantages of the composite leadframes of the invention will become more clear from the examples which follow.



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EXAMPLE 1

Leadframe coupons of copper alloy C194 (nominal composition by weight 97.5% copper, 2.35% iron, 0.3% phosphorous and 0.12% zinc) sized 4.76 mm x 25.4 mm x .25 mm (3/16" x 1.0" x .010") were degreased in acetone or propanol and then pickled in sulfuric acid (12 weight percent at 50°C). Following rinsing and drying, the samples were oxidized at 250°C in air at a 20-25°C dew point. The coupons were then divided into three groups. A first sample (Designated "A" in Table 1 below) represented the prior art and was encapsulated without further pretreatment. The coupons were then partially encapsulated by an epoxy molding resin, Nitto 180B manufactured by Nitto Denko Corporation of Osaka, Japan. Encapsulation comprised heating the resin with the partially embedded coupon to a temperature of 170-190°C for a time of 2.5-3.0 minutes at a pressure of 34.5 MPa-41.4MPa (5000-6000 psi).

A second sample (designated "B" in Table 1) was cut to the same coupon size and then coated with the adhesion promoting compound. The compound was provided as a mixture of ethylene vinyl acetate/hexane/acetone at the approximate ratio of 24.29 volume percent:20.02%:45.71%. The coupons were air dried. Following drying, the ethylene vinyl acetate thickness was about 40 angstroms. The coupons were encapsulated in the Nitto 180B resin.

A third set of samples (designated "C" in Table 1) was cleaned as above and then laminated on both sides with .13 mm (.005 inches) of Hysol XEA9684 adhesive. The epoxy film was tacked at 100°C for three minutes prior to encapsulation. The third set of coupons was then encapsulated in Nitto 180B resin.

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Figure 5 illustrates how adhesion was evaluated. A leadframe coupon 50 was partially embedded in molding resin 52. A shear stress was applied by pulling the coupon 50 and molding resin 52 in opposing direction as generally indicated by stress arrows 54. Any suitable tensile testing apparatus such as those manufactured by Instron Corporation of Canton, Massachusetts, may be used to apply the necessary shear stress. The force required to remove the test lead coupon 50 from the molding resin 52 was recorded. The higher the force, the better the adhesion between the molding compound 52 and the simulated lead 50.

To further evaluate the bond strength, the samples were aged by immersion in a pressure cooker at 121° in steam at a pressure of 1034 gm/cm<sup>2</sup> (14.7 psi). Exposure time under pressure was either 5 hours or 96 hours. The samples were then heated and solder coated to simulate soldering to a printed circuit board.

As illustrated in Table 1, the samples formed according to the process of the invention varied from 3 to 5 times superior in adhesion than leadframe samples cleaned according to conventional processes.

TABLE 1

SHEAR LOAD TO REMOVE LEAD FROM MOLDING ENCAPSULANT

25

	<u>AS Cured</u>		<u>Pressure Cooker</u> <u>5 Hours</u>		<u>Pressure Cooker</u> <u>96 Hours</u>	
	<u>MPa</u>	<u>PSI</u>	<u>MPa</u>	<u>PSI</u>	<u>MPa</u>	<u>PSI</u>
A	2.28	330	2.07	300	1.86	270
B	7.24	1050	5.86	850	5.17	750
30 C	*	*	*	*	7.24	1050

\* = shear stress in excess of 10.34 MPa (1500 psi), failure was within the copper coupon rather than at the resin/copper bond.

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The example clearly shows the composite leadframes of the invention are superior to conventional metal leadframes in reducing the possibility of moisture penetration into the package. An adhesion promoting compound may be used alone as illustrated by Group B of the Table. Generally, the thickness of the adhesion promoting compound when used by itself will be from about 20 to about 100 angstroms. When used in combination with the first polymer, the thickness of the adhesion promoting compound should also be in the range of from about 20 to about 100 angstroms. It is believed even better results will be achieved by combining the adhesion promoting compounds with the epoxy coatings of Group C.

While the invention has been described in terms of a quad leadframe (leads approaching the central aperture from four sides), it is equally applicable to DIPs (leads approaching from two opposing sides) and SIPs (leads approaching from a single side) as well as any other conductor configurations.

While the invention has particular utility in molded plastic electronic packages, the concepts may be applied to an adhesively sealed metal package as shown in Figure 6. The metal package has metallic base 54 and cover 58 components joined together by a polymer adhesive 60 such as an epoxy. Preferably, the metallic components are formed from copper, aluminum or alloys thereof to exploit the high thermal conductivity of those materials. Most preferably, an aluminum alloy such as alloy 3003 (nominal composite by weight .12% copper, 1.2% manganese and the balance aluminum) is used.

The leadframe 10 is a composite, comprising a conductor 62 and a first polymer 64. The first polymer is as described hereinabove and serves to promote adhesion between the conductor and the polymer adhesive

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60. Typically, the first polymer will be in the form of a ring having peripheral dimension defined by the area of contact between the conductor 62 and polymer adhesive. However, the width of the first polymer may  
5 be either smaller or larger than the width of the polymer adhesive.

An integrated circuit device may be bonded directly to the base component 58 or attached to a centrally positioned die attach pad (not shown). The device is  
10 then electrically connected to the conductor by bonding wires 30.

It is apparent that there has been provided in accordance with this invention a composite leadframe having improved adhesion to a molding resin which serves  
15 to reduce the popcorn effect in molded plastic packages and fully satisfies the objects, features and advantages set forth here and above.

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WHAT IS CLAIMED IS:

1. A leadframe 10 for an electronic package 32', 54, characterized by;  
a conductor 35 having a plurality of leads 12 with inner 18 and outer 14 portions, said inner portions 18  
5 defining a central aperture 22;  
a die attach paddle 24 located within said central aperture 22 and having first 47 and second 44 major surfaces, said first 47 major surfaces adapted to receive an electronic device 28; and  
10 a polymer 42 coating on at least a portion of said inner leads 18 and on both major surface 47, 44 of said die attach paddle 24.
2. The leadframe 10 of claim 1 characterized in that said first polymer 42 coats the entire inner lead portion 18 except for the lead tips 20.
3. The leadframe 10 of claim 1 characterized in that said conductor 35 is a copper alloy.
4. The leadframe 10 of claim 3 characterized in that a first polymer 42 coats the entire inner portion of the leads 18 except for the lead tips 20 as well as the second 44 major surface of said die attach paddle 24  
5 and a second polymer coats said first 47 major surface of said die attach paddle 24.
5. The leadframe 10 of claim 3 characterized in that a polymer coats the entire inner portion except for the lead tips 20 as well as both said first 47 and second 44 major surfaces of said die attach paddle 24.
6. The leadframe 10 of claim 4 characterized in that said second polymer coating is conductive.

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7. The leadframe 10 of claim 6 characterized in that said second polymer is a silver filled epoxy.

8. The leadframe 10 of claim 4 characterized in that said first polymer 42 is selected from the group consisting of polyolefins, polyimides, epoxies, acrylics and urethanes.

9. The leadframe 10 of claim 8 characterized in that said first polymer 42 is an epoxy.

10. The leadframe 10 of claim 9 characterized in that said first polymer 42 has a thickness of from about .013 (.0005 inches) to about .51 mm (.020 inches).

11. The leadframe 10 of claim 10 characterized in that said first polymer 42 has a thickness of from about .025 mm (.001 inches) to about .13 mm (.005 inches).

12. The leadframe 10 of claim 11 characterized in that said first polymer 42 is an epoxy sheet of a desired thickness tacked to said conductor.

13. The leadframe 10 of claim 10 characterized in that an adhesion promoting layer 48 is disposed between said first polymer 42 and said conductor 35.

14. The leadframe 10 of claim 13 characterized in that said adhesion promoting layer 48 is selected from the group consisting of refractory oxides, dull nickel, phosphates and polymers.

15. The leadframe 10 of claim 14 characterized in that said adhesion promoting layer 48 is a polymer selected from the group consisting of benzotriazole, benzothiazole, mercaptoester, 5-carboxy-benzotriazole,



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- 5 5-(1-aminoethylamido)-benzotriazole, 5-amido-benzotriazole and ethylene vinyl acetate.

16. The leadframe 10 of claim 15 characterized in that said adhesion promoting layer 48 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.

17. The leadframe 10 of claim 4 characterized in that said first polymer 42 is selected from the group consisting of benzotriazole, benzothiazole, mercapto-ester, 5-carboxy-benzotriazole, 5-(1-amino-ethylamide)-  
5 benzotriazole, 5-amidobenzotriazole and ethylene vinyl acetate.

18. The leadframe 10 of claim 17 characterized in that said first polymer 42 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.

19. A molded plastic electronic package 32' characterized by:

- a composite leadframe 10, said leadframe 10 comprising a conductor 35 having a plurality of leads 12  
5 with inner 18 and outer 14 portions, said inner lead portions 18 defining a central aperture 22 and a first polymer 42 coating said inner portion 18 except for the lead tips 20;

an integrated circuit device 28 electrically  
10 connected 30 to said inner lead portions 18; and

a molding resin 34 encapsulating said inner leads 18 and integrated circuit 28.

20. The package 32' of claim 19 characterized in that said conductor 35 is a copper alloy.

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21. The package 32' of claim 20 characterized in that said conductor 35 includes a die attach paddle 24 located within said central aperture 22 and having first 47 and second 44 major surfaces, said first 47 major surface adapted to receive an electronic device 28 and said first polymer 42 coats said second 44 major surface of said die attach paddle 24.

22. The package 32 of claim 21 characterized in that a polymer 42 coats both major surfaces 47,44 of said die attache paddle 24.

23. The package 32' of claim 21 characterized in that the polymer 42 coating said first major surface 47 is a second polymer different from the polymer 42 coating said second 44 major surface and said inner leads 18.

24. The package of claim 23 characterized in that said first polymer 42 is selected from the group consisting of polyolefins, polyimides, epoxies, acrylics and urethanes.

25. The package 32' of claim 23 characterized in that said first polymer 42 is an epoxy with a thickness of from about .025 mm (.001 inches) to about .13 mm (.005 inches).

26. The package 32' of claim 25 characterized in that an adhesion promoting layer 48 is disposed between said first polymer 42 and said conductor 35.

27. The package 32' of claim 26 characterized in that said adhesion promoting layer 48 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.

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28. The package 32' of claim 20 characterized in that said first polymer 42 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.

29. The metal electronic package 54 characterized by:

- a metallic base component 56;
- a metallic cover component 58;
- 5 a composite leadframe 10 disposed between said base component 56 and said cover component 58, said leadframe 10 comprising a conductor 62 having a plurality of leads 12 with inner 18 and outer 14 portions, said inner lead portions 18 defining a central aperture 22 and a first
- 10 polymer 64 coating a portion of said inner portion 18;
- an integrated circuit device 28 electrically connected 30 to said inner lead portions 18; and
- a polymer adhesive 60 bonding said first polymer 64 to said base 56 and cover 58 components.

30. The package 54 of claim 29 characterized in that said metallic base 56 and cover 58 components are individually selected to be copper, aluminum or alloys thereof.

31. The package 54 of claim 30 characterized in that said metallic base 56 and cover 58 components are selected to be an aluminum alloy.

32. The package 54 of claim 30 characterized in that said conductor 62 is a copper alloy and said first polymer 64 is selected from the group consisting of epoxy and ethylene vinyl acetate.

33. The package 54 of claim 32 characterized in that said first polymer 64 is selected to be an epoxy.

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34. The package 54 of claim 32 characterized in that an adhesion promoting layer 48 is disposed between said first polymer 64 and said conductor 62.

35. The package 54 of claim 34 characterized in that said bonding adhesive 60 is an epoxy.

36. A leadframe 10 for an electronic package characterized by:

5 a conductor 35 having a plurality of leads 12 with inner and outer portions, said inner portions defining a central aperture 22;

a die attach paddle 24 located within said central aperture 22 and having first 47 and second 44 major surfaces, said first 47 major surface adapted to receive an electronic device 28; and

10 a polymer coating at least a portion of said inner leads 18 and the second surface of said die attach paddle 24, said polymer coating having a thickness from about .013 mm (.0005 inches) to about .51 mm (.020 inches).

37. The leadframe 10 of claim 36 characterized in that said conductor 35 is a copper alloy.

38. The leadframe 10 of claim 37 characterized in that said polymer coating is in the form of a preform tacked to both said inner portion of the leads and to said second surface of said die attach paddle 24.

39. The leadframe 10 of claim 38 characterized in that said polymer is selected from the group consisting of polyolefins, polyimides, epoxies, acrylics and urethanes.

40. The leadframe 10 of claim 39 characterized in that said polymer is an epoxy.

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41. The leadframe 10 of claim 40 characterized in that said polymer has a thickness of from about .001 to about .005 inches.

42. The leadframe 10 of claim 40 characterized in that an adhesion promoting layer 48 is disposed between said polymer and said conductor 35.

43. The leadframe 10 of claim 42 characterized in that said adhesion promoting layer 48 is selected from the group consisting of refractory oxides, dull nickel, phosphates, and polymers.

44. The leadframe 10 of claim 43 characterized in that said adhesion promoting layer 48 is a polymer selected from the group consisting of benzotriazole, benzothiazole, mercaptoester, 5-carboxy-benzotriazole, 5-(1-amino-ethylamido)-benzotriazole, 5-amido-benzotriazole and ethylene vinyl acetate.

45. The leadframe 10 of claim 44 characterized in that said adhesion promoting layer 48 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.

46. A leadframe 10 for an electronic package, characterized by:

a conductor 35 having a plurality of leads with inner and outer portions, said inner portions defining a central aperture 22;

a die attach paddle 24 located within said central aperture 22 and having first 47 and second 44 major surfaces, said first 47 major surface adapted to receive an electronic device 28; and

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10 a polymer coating at least a portion of both said  
inner leads and said second 44 major surface of said die  
attach paddle 24, said polymer selected from the group  
consisting of benzotriazole, benzothiazole, mercapto-  
ester, 5-carboxy-benzotriazole, 5-(1-amino-ethylamido)-  
15 benzotriazole, 5-amido-benzotriazole and ethylene vinyl  
acetate.

47. The leadframe 10 of claim 46 characterized in  
that said conductor 35 is a copper alloy.

48. The leadframe 10 of claim 47 characterized in  
that said polymer has a thickness of from about .013 mm  
(.0005 inches) to about .51 mm (.020 inches).

49. The leadframe 10 of claim 48 characterized in  
that said polymer has a thickness of from about .025 mm  
(.001) to about .13 mm (.005 inches).

50. The leadframe 10 of claim 49 characterized in  
that said polymer is an epoxy sheet tacked to said  
conductor 35.

51. The leadframe 10 of claim 48 characterized in  
that an adhesion promoting layer 48 is disposed between  
said first polymer 42 and said conductor 35.

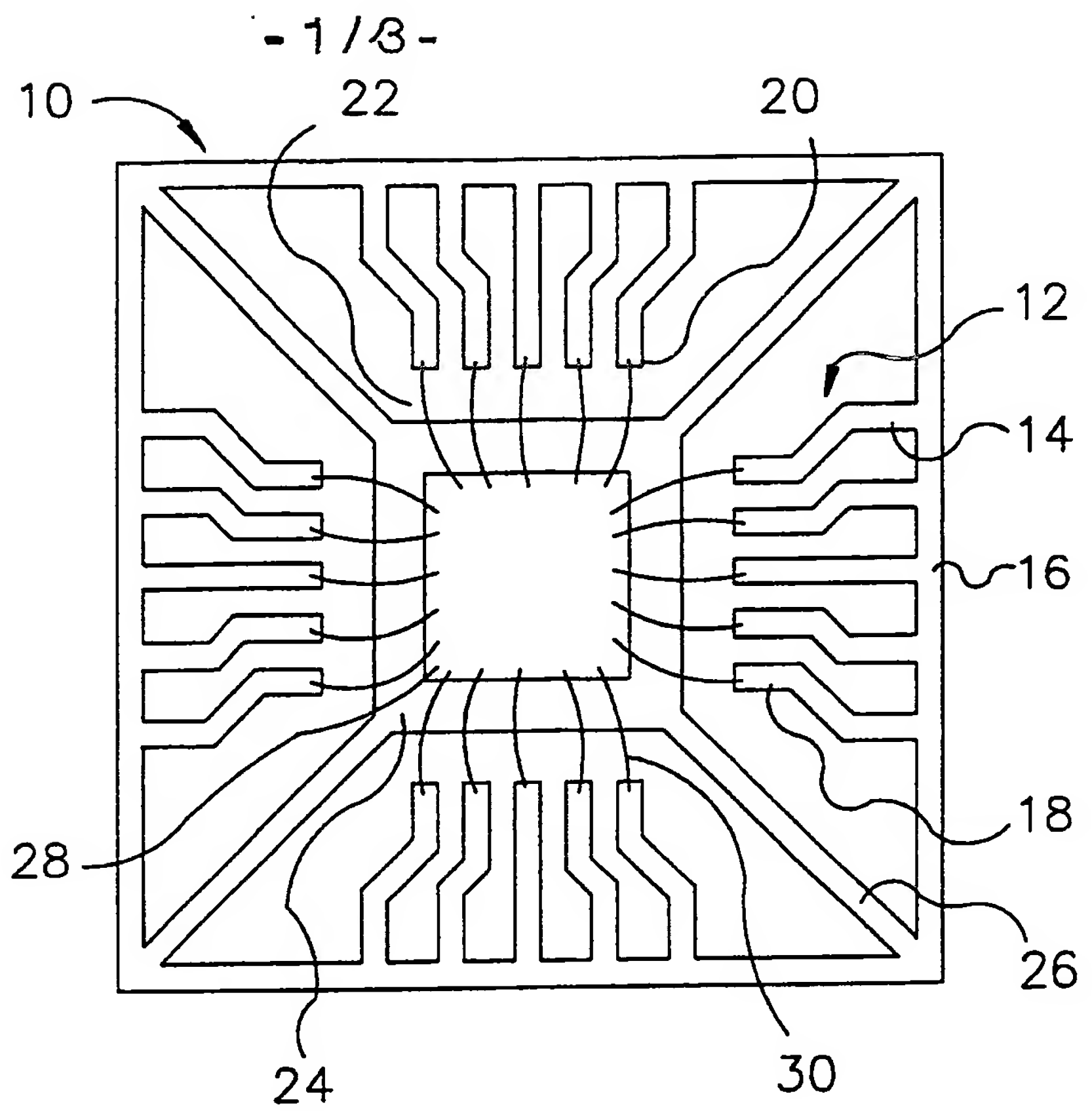
52. The leadframe 10 of claim 48 characterized in  
that said adhesion promoting layer 48 is selected from  
the group consisting of refractory oxides, dull nickel,  
phosphates, and polymers.

53. The leadframe 10 of claim 48 characterized in  
that said first polymer 42 is ethylene vinyl acetate  
having a thickness of from about 20 to about 100  
angstroms.



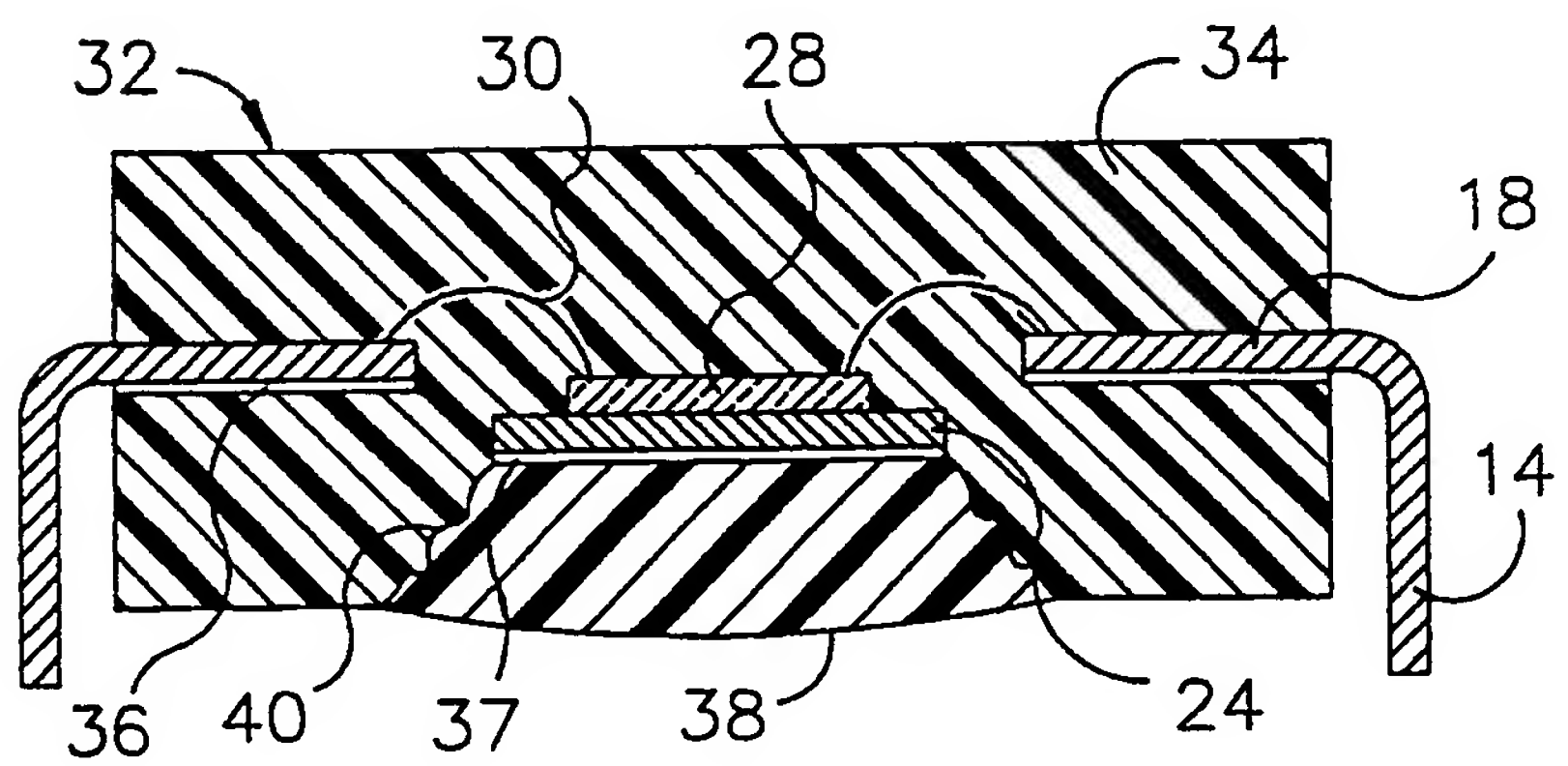
-25-

54. The leadframe 10 of claim 52 characterized in that said first polymer 42 is ethylene vinyl acetate having a thickness of from about 20 to about 100 angstroms.



PRIOR ART

FIG. 1



PRIOR ART

FIG. 2

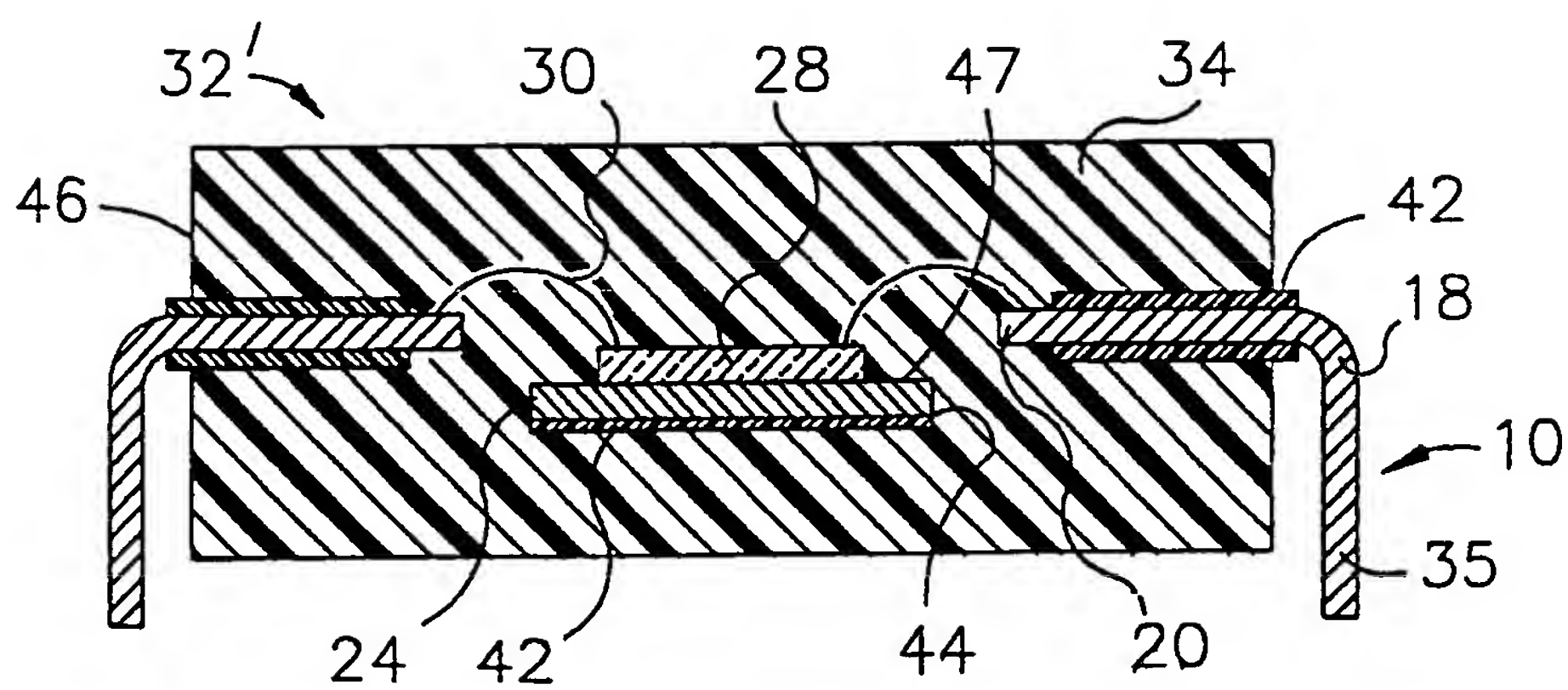


FIG. 3 ✓

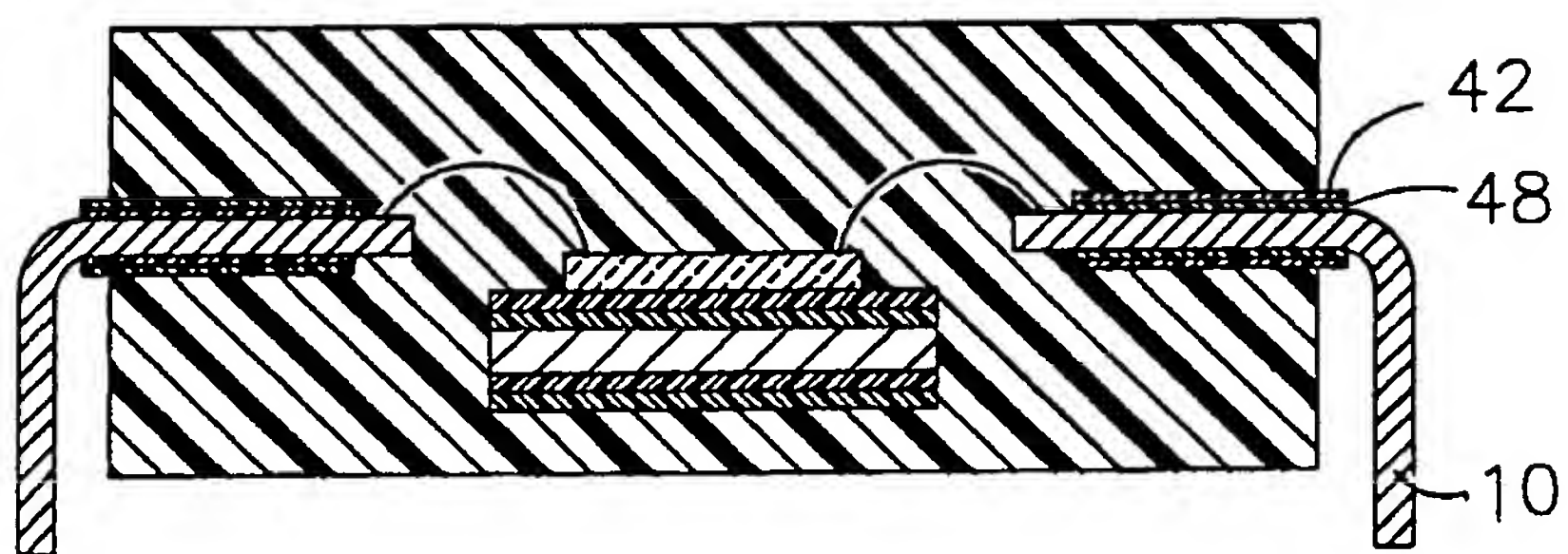


FIG. 4

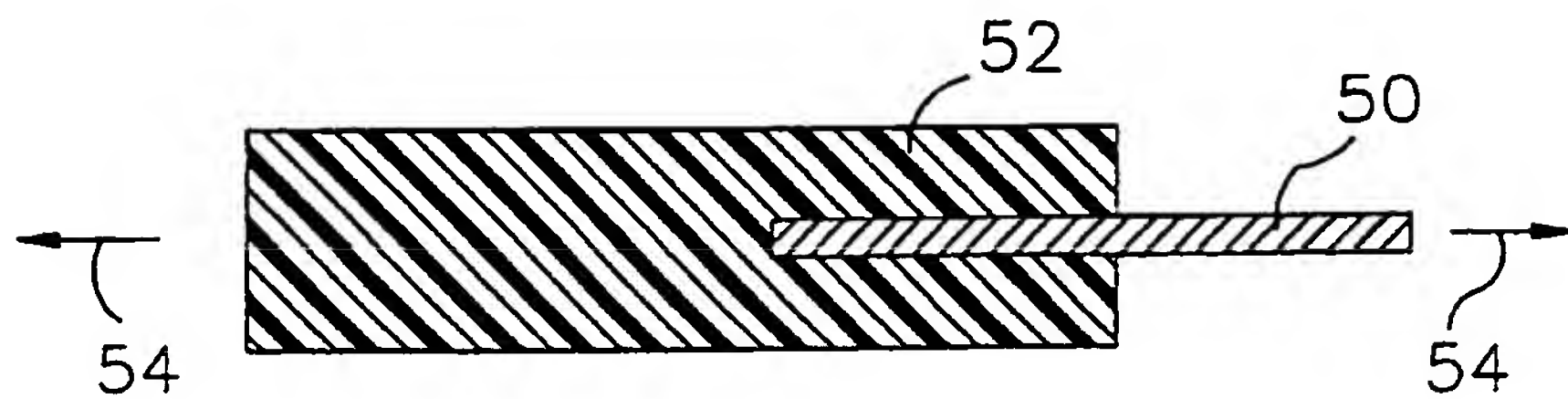


FIG. 5

3/3

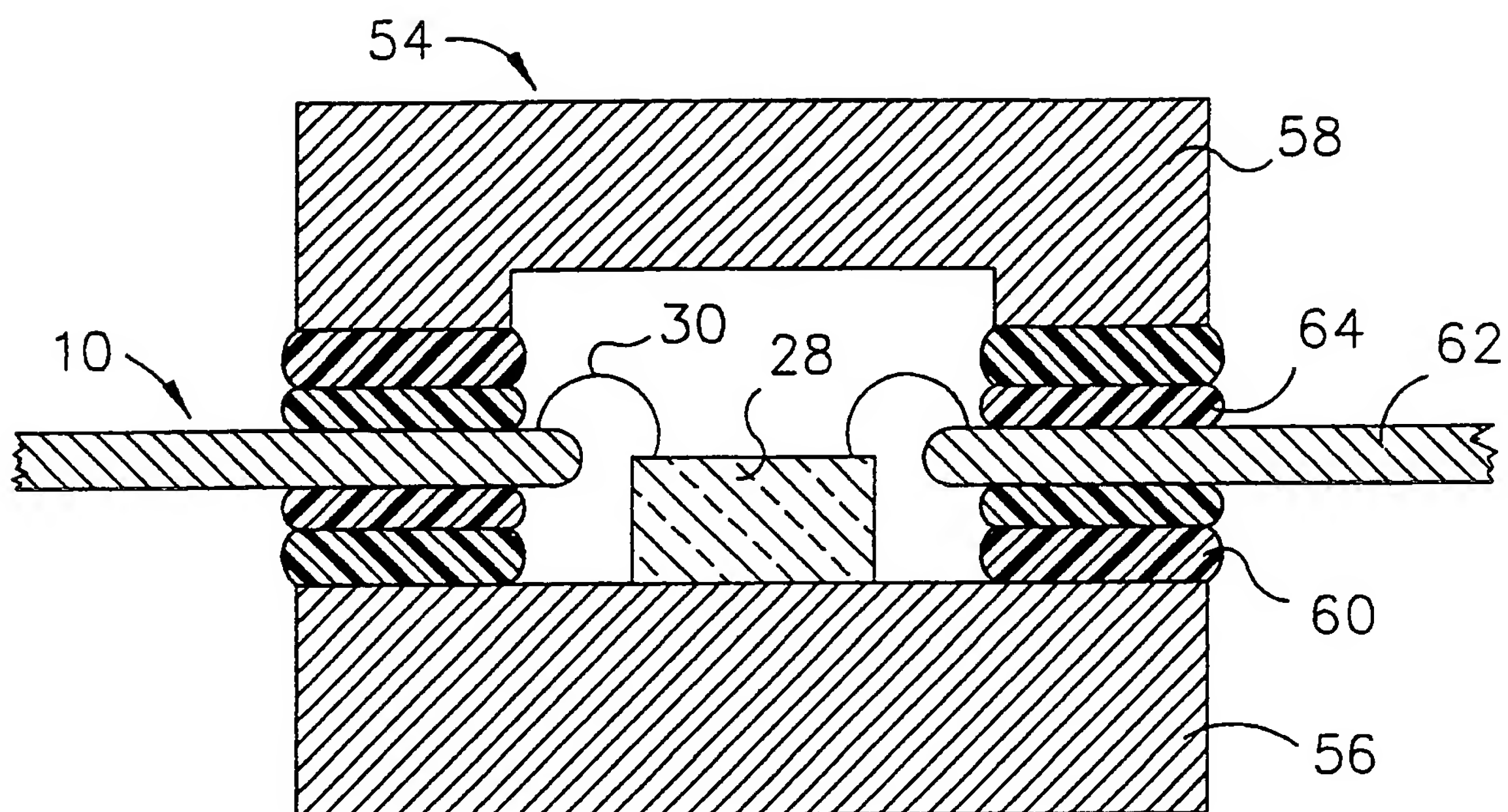


FIG. 6

# INTERNATIONAL SEARCH REPORT.

International Application No PCT/US91/05860

<b>I. CLASSIFICATION OF SUBJECT MATTER</b> (if several classification symbols apply, indicate all) <sup>1</sup>		
According to International Patent Classification (IPC) or to both National Classification and IPC		
INT. CL. (5): H01L 23/14, 23/50		
U.S. CL. 357/70,72,74; 174/54.2, 54.4		
<b>II. FIELDS SEARCHED</b>		
Minimum Documentation Searched <sup>4</sup>		
Classification System	Classification Symbols	
U.S.	357/70,72,74 174/54.2, 54.4	
Documentation Searched other than Minimum Documentation to the Extent that such Documents are Included in the Fields Searched <sup>5</sup>		
<b>III. DOCUMENTS CONSIDERED TO BE RELEVANT</b> <sup>11</sup>		
Category <sup>6</sup>	Citation of Document, <sup>12</sup> with indication, where appropriate, of the relevant passages <sup>13</sup>	Relevant to Claim No. <sup>14</sup>
Y	JP, A, 2-63148 (HISAMUNE) 02 MARCH 1990, See Abstract	1-28, 36-54
Y	JP, A, 59-219948 (YAMANAKA) 11 DECEMBER 1984, See Abstract	1-28, 36-54
Y	JP, A, 59-154051 (YAMADA) 03 SEPTEMBER 1984, See Abstract	1-28, 36-54
A	JP, A, 1-321664 (NAKAMURA) 27 DECEMBER 1989, See Abstract	1-28, 36-54
A	JP, A, 1-73751 (OKUNOYAMA) 20 MARCH 1989 See Abstract	1-28, 36-54
A, P	US, A, 4,985,751 (SHIOBARA ET. AL) 15 JANUARY 1991 See entire document.	1-28, 36-54
<p><sup>15</sup> Special categories of cited documents: <sup>16</sup></p> <p>"A" document defining the general state of the art which is not considered to be of particular relevance</p> <p>"E" earlier document but published on or after the international filing date</p> <p>"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)</p> <p>"O" document referring to an oral disclosure, use, exhibition or other means</p> <p>"P" document published prior to the international filing date but later than the priority date claimed</p> <p>"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention</p> <p>"X" document of particular relevance: the claimed invention cannot be considered novel or cannot be considered to involve an inventive step</p> <p>"Y" document of particular relevance: the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art</p> <p>"Δ" document member of the same patent family</p>		
<b>IV. CERTIFICATION</b>		
Date of the Actual Completion of the International Search <sup>17</sup>		Date of Mailing of this International Search Report <sup>18</sup>
22 NOVEMBER 1991		13 DEC 1991
International Searching Authority <sup>19</sup>		Signature of Authorized Officer <sup>20</sup>
ISA/US		SHEILA V. CLARK / 169th / 11/9/91
		NGUYEN NGOC HO
		INTERNATIONAL DIVISION

III. DOCUMENTS CONSIDERED TO BE RELEVANT (CONTINUED FROM THE SECOND SHEET)		
Category *	Citation of Document, <sup>1a</sup> with indication, where appropriate, of the relevant passages <sup>1b</sup>	Relevant to Claim No <sup>1c</sup>
A	US, A, 4,939,316 (MAHULIKAR ET. AL.) 03 JULY 1990, See entire document.	29-35
A,P	US, A, 5,023,398 (MAHULIKAR ET. AL.) 11 JUNE 1991, See entire document.	29-35
A	US, A, 4,888,449 (CRANE ET. AL.) 19 DECEMBER 1989, See entire document.	29-35
A,P	US, A, 5,013,871 (MAHULIKAR ET. AL.) 07 MAY 1991, See Entire Document.	29-35



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